

IN THE CLAIMS:

1. to 21. (Canceled)

22. (Currently Amended) A low reflective antistatic hardcoat film comprising:

a transparent substrate film;

a transparent conductive layer formed on the transparent substrate film;

a hardcoat layer formed on the transparent conductive layer, the hardcoat layer comprising an anisotropic conductive layer of which the volume resistivity in the direction of the plane in the layer is higher than the volume resistivity in the layer thickness direction, ~~the hardcoat layer formed on the conductive layer and~~ comprising a plurality of layers; and

a low refractive layer formed on the hardcoat layer,

the low refractive layer having a lower refractive index than the hardcoat layer.

23. (Previously Presented) The low reflective antistatic hardcoat film according to claim 22, wherein fine irregularities

are formed on a surface of the hardcoat layer and/or a surface of the low refractive layer.

24. (Previously Presented) The low reflective antistatic hardcoat film according to claim 22, wherein the hardcoat layer is conductive.

25. (Previously Presented) The low reflective antistatic hardcoat film according to claim 22, wherein the hardcoat layer comprises the reaction product of a reaction curing resin composition.

26. (Previously Presented) The low reflective antistatic hardcoat film according to claim 22, wherein the hardcoat layer has a high refractive index.